What is claimed is:

1. An anti-reflective and anti-static structure for a display device, comprising a glass substrate, and an ITO layer, a first $Nb_2O_5$ layer, a first $SiO_2$ layer, a second $Nb_2O_5$ layer, and a second $SiO_2$ layer successively formed in that order on the glass substrate.

2. The structure of claim 1, wherein the ITO layer has a thickness of about 17 ~ 19 nm.

3. The structure of claim 1, wherein the first $Nb_2O_5$ layer has a thickness of about 3 ~ 5 nm to thereby increase adhesion strength between the ITO layer and the first $SiO_2$ layer.

4. The structure of claim 1, wherein the first $SiO_2$ layer has a thickness of about 28 ~ 29 nm.

5. The structure of claim 1, wherein the second $Nb_2O_5$ layer has a thickness of about 110 ~ 120 nm.

6. The structure of claim 1, wherein the second $SiO_2$ layer has a thickness of about 90 ~ 100 nm.

7. The structure of claim 1, wherein the glass substrate

has an average surface roughness of more than 2.10 Å and a peak-to-valley surface roughness of more than 40.1 Å.

8. The structure of claim 7, wherein the glass substrate has an average surface roughness of about 6.14 Å and a peak-to-valley surface roughness of about 106 Å.

9. The structure of claim 3, wherein the glass substrate has an average surface roughness of more than 2.10 Å and a peak-to-valley surface roughness of more than 40.1 Å

10. The structure of claim 9, wherein the glass substrate has an average surface roughness of about 6.14 Å and a peak-to-valley surface roughness of about 106 Å.